

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	7897	(118/715,663,689,688,690,691,692,712,713).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/28 20:48
L4	34	L3 and (concentration adj detector)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L5	53	L3 and (concentration adj sensor) and control\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L6	832	(gas adj concentration adj (sensor or detector)) and control\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L7	92	(L6 and (manometer or (pressure adj sensor))) not engine	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L8	43	L7 and (semiconductor or wafer or substrate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L9	445	L3 and (manometer or (pressure adj sensor))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L10	84	L3 and (concentration adj (sensor or detector))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48

L11	10	L9 and L10	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L12	79	((concentration adj (sensor or detector)) same (manometer or (pressure adj sensor))) and control\$4 and (semiconductor or wafer or substrate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L13	65	L12 not engine	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L14	383	(ftir or (fourier transform infrared spectrometer)) same mirror	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L15	32	L14 same heat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L16	10	(ftir or (fourier transform infrared spectrometer)) same (mirror with heat\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:48
L18	4	L3 and (gas adj concentration adj (sensor or detector))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:50
L19	5	(L4 OR L5 OR L8 OR L18 OR L10 OR L11 OR L13 OR L15 OR L16) and @pd>="20050620" and (@rlad<="20030710" or @ad<="20030710")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:57

L20	191	L6 and (semiconductor or wafer or substrate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:57
L21	167	(20) and (@rlad<="20030710" or @ad<="20030710")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:58
L22	23	21 and (vaporiz\$4 or evaporat\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/11/28 20:59
L23	1	("2004/0007180").URPN.	USPAT	ADJ	ON	2005/11/28 21:00
L24	10	("20010050096"   "20030236001"   "20040007180"   "5376409"   "5436457"   "5518528"   "6089027"   "6617175"   "6631334"   "6772781").PN. OR ("6909973").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2005/11/28 21:01